Supporting Information:

Transparent Conductive Printable Meshes
Based on Percolation Patterns

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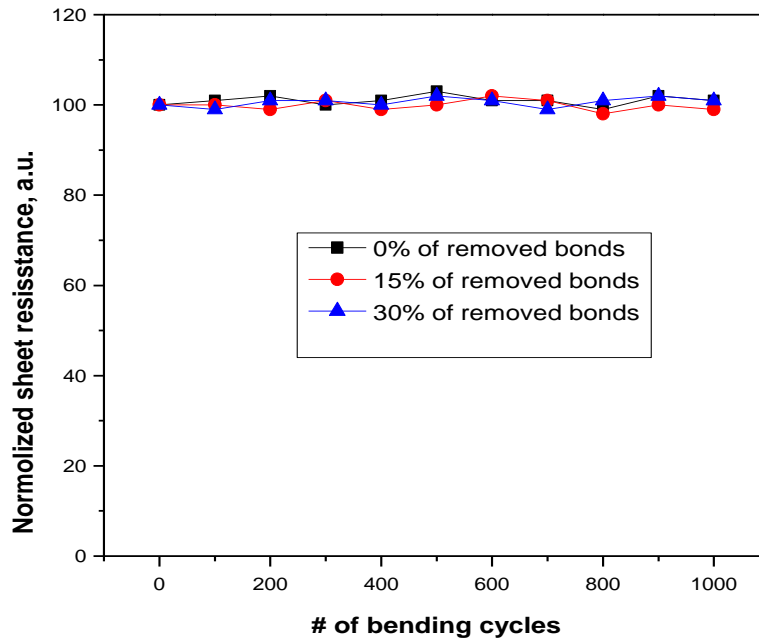
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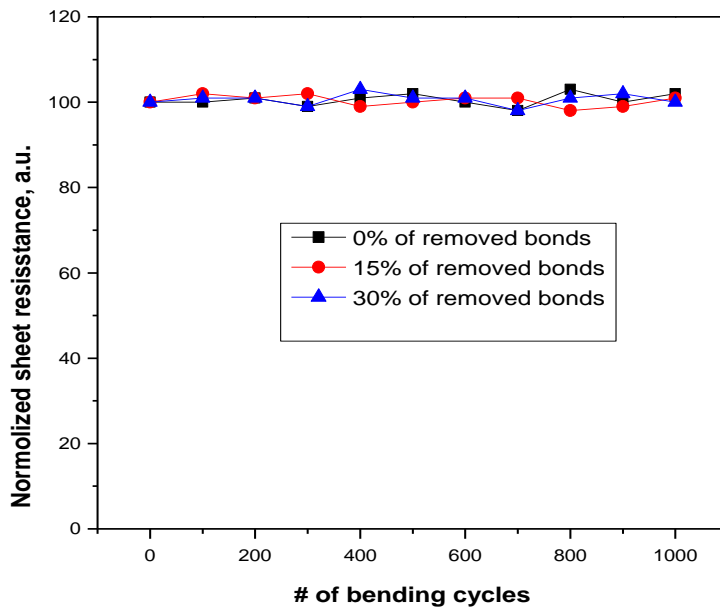[†]These authors contributed equally.

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Figure 1S: Dependencies of the sheet resistance on the number of the bending cycles for regular square mesh and percolation meshes with 10 % and 20% of removed bonds. The line width is 60 µm (**a**) and 120 µm (**b**).